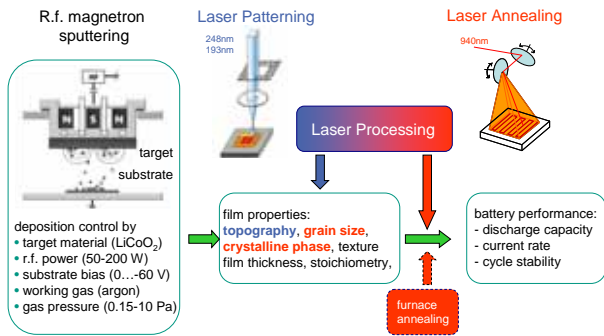


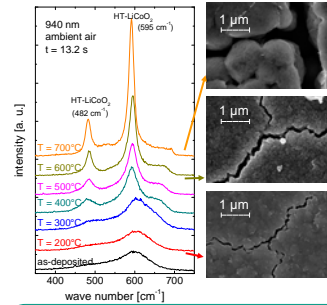
## Introduction / Motivation



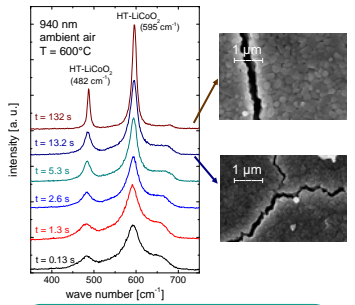
**Motivation:** Thin film electrodes are used to create high performance lithium ion batteries. Large surface area allows for high lithium diffusion and thereby high charging currents.  
**Objective:** Defined adjustment of thin film properties  
**Approach:** Combination of thin film deposition and selective laser processing

## Laser annealing

Influence of annealing temperature (Raman)



Influence of annealing time (Raman)

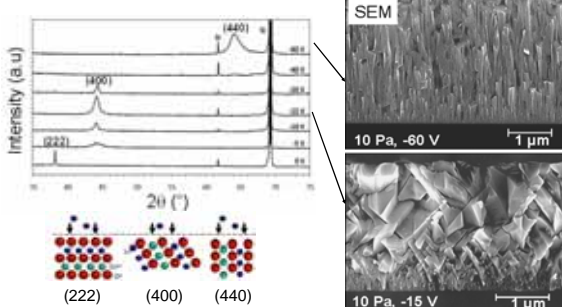


- transformation to HT-LiCoO<sub>2</sub> with increasing temperature
- crack formation occurs even at low temperatures, though film adhesion persists
- the crystallite sizes range from 10 - 20 nm (as-deposited film) about 100 nm (annealed at 600°C) >1 µm (increased grain growth at 700°C)

- transformation to HT-LiCoO<sub>2</sub> with increasing annealing time
- the crystallite sizes range from 10 - 20 nm (as-deposited film) about 100 nm (annealed for 13.2 s) about 200 nm (annealed for 132 s)

## Thin film deposition

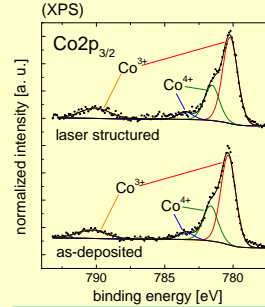
Adjustment of crystalline orientation via substrate bias (XRD)



- The thin film deposition parameters have significant influence on film properties:
- stoichiometry can be influenced by working gas pressure (with 10 Pa nearly stoichiometric LiCoO<sub>2</sub> films are created)
  - substrate bias can control the thin film density, morphology and the texture. The crystalline orientation of the thin films can be adjusted → optimization of electrochemical properties.

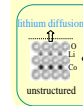
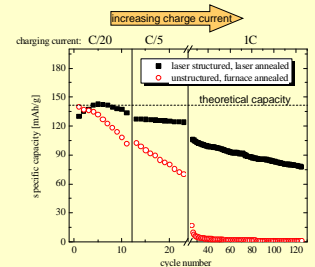
## Analytics and battery cycling

Chemical surface composition (XPS)



- main peak from Co<sup>3+</sup>, but Co<sup>4+</sup> was also detected
- after laser structuring no significant surface changes were detectable

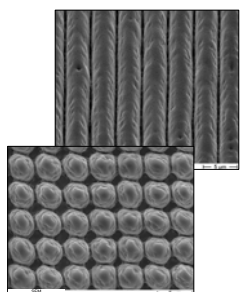
Battery cycling



- laser structuring leading to increased surface area and enhanced lithium diffusion
- improved battery performance especially at high charging currents

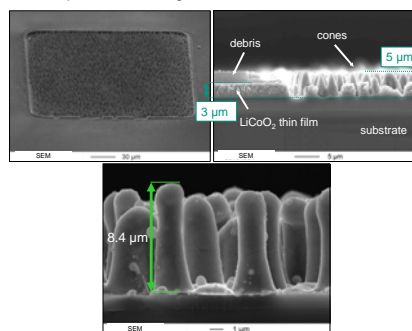
## Laser patterning

Direct structuring via mask imaging



- grating and line patterns with minimum channel widths ~ 600 nm
- high laser fluences (>2 J/cm<sup>2</sup>) lead to smooth ablation

Large area structuring using re-deposition process creating conical surface structures



- selective material ablation and re-deposition lead to growth of surface structures
- growth of cones (up to 8.4 µm)
- small material loss (0% - 20%)

## Outlook

